Identification of eta-carbide in a commercial Ni-Mo alloy (Hastelloy| alloy B-2)

The commercial Hastelloy* alloy B-2 is essentially a Ni-Mo alloy where the carbon content is kept at a low level in order to achieve an acceptable corrosion resistance in the as-welded condition [1]. Recently, a minute amount of the intermetallic NiMo (6-phase) has been identified in a heat containing less than 0.002 weight per cent carbon [2]. It is the objective of this note to report on the identification by electron diffraction and microscopy of a grain boundary eta-carbide phase in aged samples of a heat containing 0.002 weight per cent carbon.

Table I shows the chemical composition of the heat investigated. The heat treatment consisted of annealing at 1065° C followed by water quenching. Annealed samples were then aged at 800° C for 1 to 100h. Thin foils for transmission electron microscopy and diffraction were prepared by jet polishing in a solution consisting of one part $HNO₃$ and three parts methanol at about -30° C. All the foils were examined in a Phllips 300EM operated at 100 kV.

Fig. 1 shows a number of selected area diffraction patterns derived at different tilts from the grain boundary particle shown in Fig. 2. All of these patterns were consistently indexed in terms of a face-centred cubic lattice. The matrix phase (f c c with $a = 0.3610$ nm) was used as an internal

Figure 1 Selected area electron diffraction patterns derived from a grain boundary carbide particle. (a) [1 $\overline{1}\overline{1}$], (b) [$\overline{1}0$ 3], (c) $[0\bar{1}5]$ and (d) $[\bar{3}3\bar{2}]$.

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Figure 2 Electron micrographs of the same grain boundary carbide particle as in Fig. 1 (beam parallel to $[1\overline{1}\overline{1}]$). (a) Bright-field image and (b) dark-field image with a (220) particle reflection.

Ni	Mo	- НΑ	ື	C٥	υı	-------	
70.42 -----------	29.92	0.93	0.64	0.10 -0	0.02	0.01 ________	0.002

TABLE I Chemical composition in weight per cent

standard in measuring the camera constant. From the observed d-spacings, the lattice constant of the grain boundary phase was calculated to be 10.86 ± 0.01 Å $(1.086$ nm). This suggests that this phase is an eta-carbide of the form M_{12} C such as that found in the ternary Ni-Mo-C system [3, 4] and in Hastelloy alloy N [5]. The present result and that reported earlier [2] concerning the presence of δ -NiMo in Hastelloy alloy B-2 seem to indicate that M_{12} C and δ -NiMo may co-exist, as has been concluded by Heijwegen and Rieck [4] in the case of the Ni-Mo-C ternary system.

References

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About the origin o f magnetoresistance in relatively thin metal films

It has previously been [1] shown that the transport properties of a thin metallic film placed in a transverse magnetic field (perpendicular to its plane) can be, as in the absence of a magnetic field, described in terms of a mean free path model [1, 2] which takes into account the background scattering and the scattering at external surfaces $[3, 4]$, i.e. the scatterings of the Fuchs-Sondheimer conduction model [4]. In this model the film conductivity, σ_F , and the Hall coefficient, R_{HF} , are evaluated by means of the following 2. H. M. TAWANCY, *J. Mater. Sci.* 15 (1980) 2597.

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analytical expressions [1]

and

$$
R_{\rm HF}/R_{\rm H0} = B[A^2 + \alpha^2 B^2]^{-1}, \qquad (2)
$$

(1)

 wh

$$
A = \frac{3}{2} \left\{ -\frac{1}{2}\mu + \mu^2 + \frac{\mu}{2} (1 - \mu^2 + \alpha^2 \mu^2) \right\}
$$

$$
\times \ln \left[\frac{(1 + \mu^{-1})^2 + \alpha^2}{1 + \alpha^2} \right]
$$

-
$$
2\alpha \mu^3 \arctan \left[\frac{\alpha}{\mu} \frac{1}{(\alpha^2 + 1 + \mu^{-1})} \right] \right\} (3)
$$

 $\sigma_{\rm F}/\sigma_0 = [A^2 + \alpha^2 B^2]A^{-1}$

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